

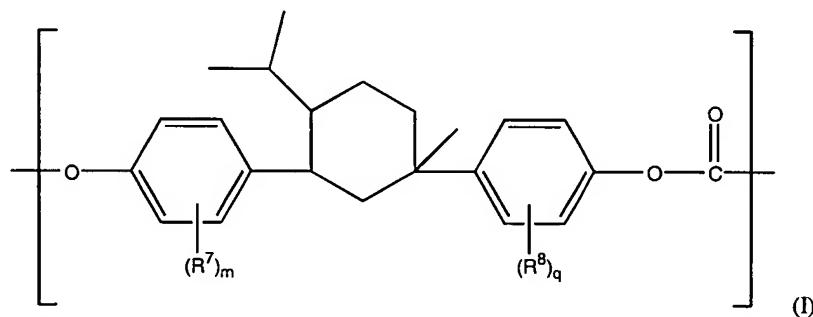
**Amendments to the Claims:**

This listing of claims will replace all prior versions, and listings, of claims in the application:

**Listing of Claims :**

Claims 1-14 (cancelled).

[c015] A method for using a polymeric substrate comprising disposing said polymeric substrate in an optical display device or a light emitting device, wherein said polymeric substrate comprises formula (I):



where the three optically active sites of (I) can be R isomers, S isomers, or combinations thereof;

R<sup>7</sup> and R<sup>8</sup> are independently selected from the group consisting of C<sub>1</sub>-C<sub>6</sub> alkyl and hydrogen;

m is an integer in a range between about 1 and about 4;

q is an integer in a range between about 1 and about 4.

[c016] The method in accordance with claim 15, wherein R<sup>7</sup> and R<sup>8</sup> are hydrogen, m is 4 and q is 4.

[c017] The method in accordance with claim 15, wherein the polymeric substrate has a glass transition temperature greater than about 235°C.

[c018] The method in accordance with claim 15, wherein the polymeric substrate has a haze less than about 4%.

[c019] The method in accordance with claim 15, wherein the polymeric substrate has a uniform thickness that varies less than about 3%.

[c20] The method in accordance with claim 15, wherein the optical display device is a liquid crystal display device.

[c021] The method in accordance with claim 15, wherein the light emitting device is an organic electroluminescent device.

[c022] The method in accordance with claim 15, wherein the polymeric substrate further comprises at least one barrier layer.

[c023] The method in accordance with claim 22, wherein the barrier layer comprises an inorganic material, organic material, or combinations thereof.

[c024] The method in accordance with claim 15, wherein the polymeric substrate further comprises at least one substantially transparent conductive layer.

[c025] The method in accordance with claim 24, wherein said substantially transparent conductive layer comprises an oxide of at least one metal selected from the group consisting of tin, cadmium, indium, zinc, magnesium, gallium, and combinations thereof.

[c026] The method in accordance with claim 25, wherein said substantially transparent conductive layer further comprises at least one dopant selected from the group consisting of gallium, aluminum, germanium, and tin.

[c027] The method in accordance with claim 26, wherein said oxide is indium tin oxide.

Claims 28-53 (Cancelled).